

Method for the Production of an Optical Glass Element

Abstract

A method for the production of an optical glass element (13) is proposed, with the following process sequence:

- a) Applying a liquid embossing material (4) on an embossing die (1),
- b) Embossing the embossing material (4) at a temperature of less than 500°C,
- c) Hardening the embossing material (4),
- d) Sintering the embossing material (4, 4') and thus executing the primary forming of the optical glass element (13).

In addition, an optical glass element that is produced with the method, a device for implementing the method, and a use of this device are proposed.

In this regard, see Figure 1a.